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SERIAL NO. PCT/JP01/01446

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**Oct. 25, 2001 (27 Feb. 2001)**

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## U.S. PATENT DOCUMENTS

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## FOREIGN PATENT DOCUMENTS

		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
							YES	NO
SP		936505 ✓	08-1999	EP				
SP		940695 ✓	09-1999	EP				
SP		602829 ✓	06-1994	EP				
SP		9-80738 ✓	03-1997	JP				✓
SP		7-219243 ✓	08-1995	JP				✓

**OTHER DOCUMENTS** (Including Author, Title, Date, Pertinent Pages, Etc.)

SP			D.M. Tennant et al, Characterization of near-field holography grating masks for optoelectronics fabricated by electron beam lithography, JOURNAL OF VACUUM SCIENCE & TECHNOLOGY B, November/December 1992, Vol. 10, No. 6, pp. 2530-2535

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							YES	NO
SP		3-188617	08-1991	JP				✓
CP		58-222523	12-1983	JP				✓
GP		59-143324	08-1984	JP				✓
SP		6-36994	02-1994	JP				✓
						TC2		

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